

CORP RATE PRESENTATION

September 2025



“World-leading supplier
of lithography solutions”



WHAT WE DO

We enable the development of nanotechnology

Obducat's business concept is to develop and supply nanolithography processing solutions for production and replication of advanced micro- and nanostructures for mass-production as well as for R&D purposes.

Since the founding of Obducat in 1989, the company has accumulated more than 35-years experience in developing and supplying innovative lithography solutions.



WHAT WE OFFER

A competitive edge, know-how
and customized solutions within:

- Nanoimprint Lithography, NIL
- Resist processing
- Wet processing
- Foundry services

We provide customers with a competitive edge through delivery of cost-effective lithography solutions. Our user-friendly turn-key systems are widely known for their high quality and low Cost-of-Ownership.





60

Highly skilled
and dedicated
specialists

700+

Customer
installations
worldwide

163

Patent applications
of which more
than 154 are
granted patents

Our facilities
encompass

2000 m²

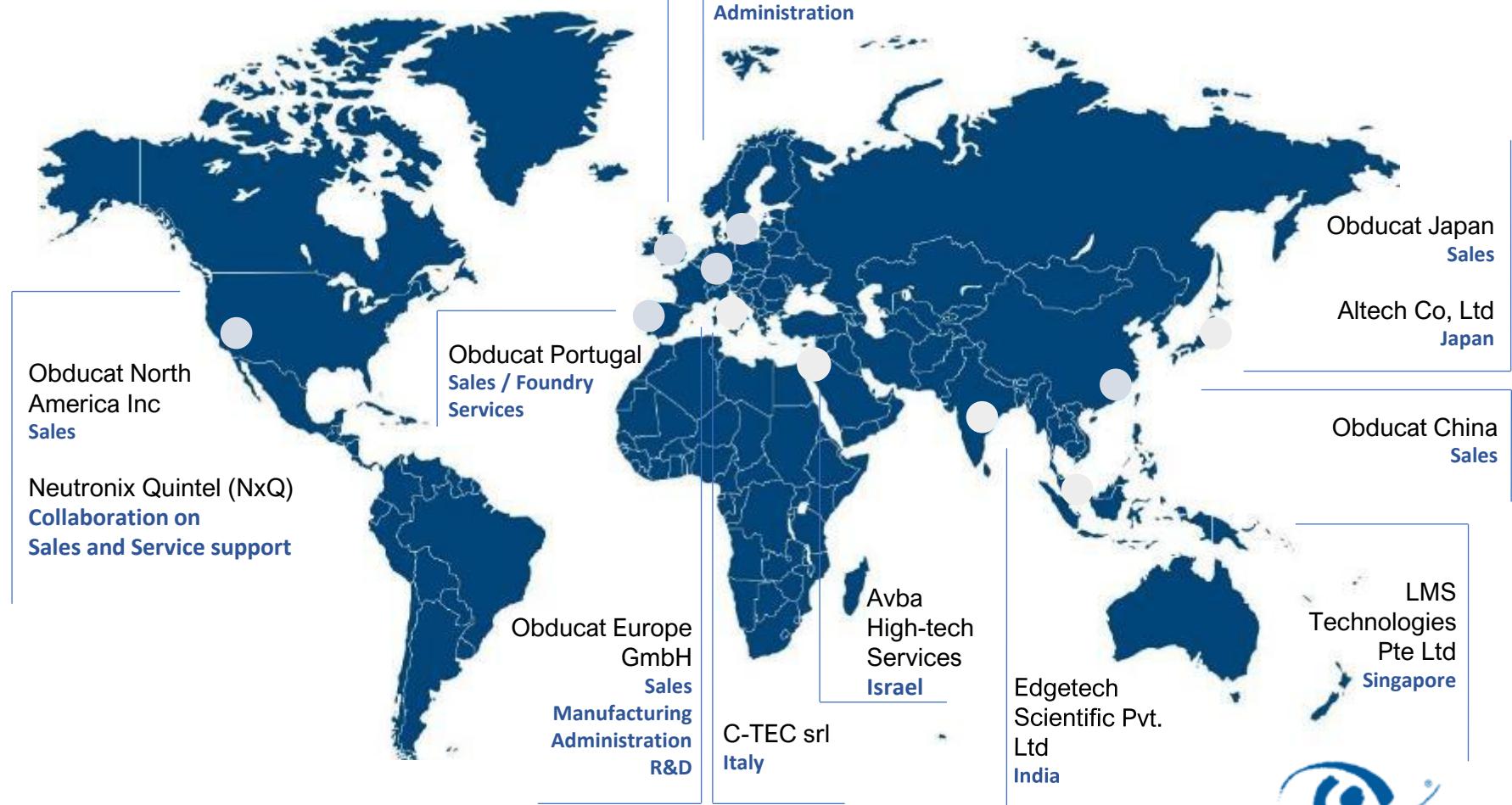
150 m² Class
10/100
cleanroom for
contract
manufacturing

Obducat is
listed on Nordic
Growth Market
Stock Exchange
in Sweden

www.ngm.se

OBDUCAT WORLDWIDE

● Obducat
● Obducat Agents



PRODUCTS & SERVICES

NanoImprint Lithography Tools



Eitre®
semi-automated
tools for substrate
sizes up to 200
mm.



Eitre® Large Substrates
semi-automated tool for
substrate sizes up to 500
mm.



Sindre® Integra
fully automated tool
for substrate sizes up
to 300 mm.



Sindre® Litho Track
fully integrated Nanoimprint
Lithography tool.

PRODUCTS & SERVICES

Resist Processing Tools



Quickstep

Semi-automated coater and developer for substrate sizes 200 and 300 mm and for large substrates up to 1500 mm.



Microcluster

Fully automated coater and developer for substrate sizes 200 and 300 mm.



Microcluster Track

Fully automated coater and developer for substrate size 200, 300 and up to 1500 mm.

PRODUCTS & SERVICES

Wet Processing Tools



Quickstep Wet

Semi-automated wet tools for cleaning, lift-off, etching or developing. Ability to process substrate sizes 200 and 300 mm and large substrates up to 1500 mm.



Microcluster Wet

Fully automated wet tools for cleaning, lift-off, etching or developing. Ability to process substrate sizes 200 and 300 mm and large substrates up to 1500 mm.



Microcluster Wet Track

Fully automated wet processing track tools for cleaning, lift-off, etching or developing. Ability to process substrate sizes 200 and 300 mm and large substrates up to 1500 mm.

FOUNDRY SERVICES



**Based on Obducat's exceptional internal
nanolithography process know-how**

Comprehensive Processing

All processes available up to 200 mm substrate size

Full Capability Range

From substrate preparation and lithography processes to advanced pattern transfer

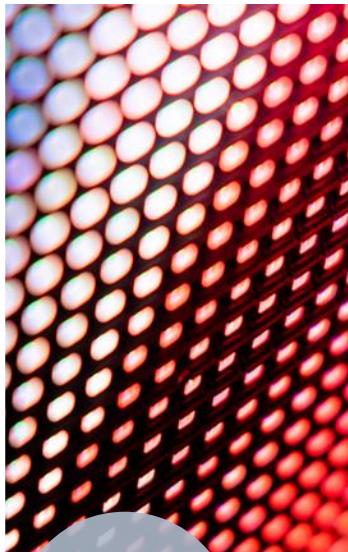
Scalable Production

Supporting prototyping to high-volume manufacturing

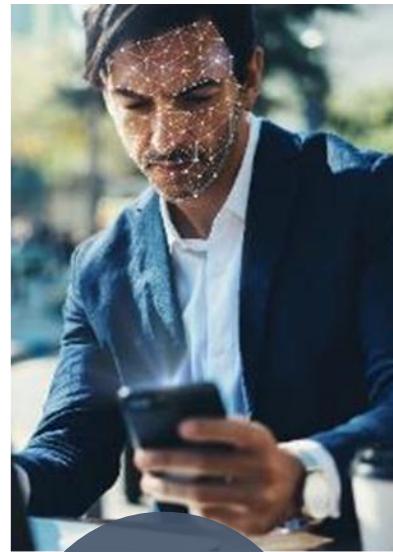
OBDUCAT MARKET FOCUS APPLICATIONS



Optical &
Photonic
Devices



LEDs &
Display



MEMS &
Sensor
Devices



Bio &
Medical
Devices



High Power &
High Frequency
Components

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THANK YOU FOR YOUR ATTENTION!

